

Fig. 3A 301 POLY-1 DEPOSITION

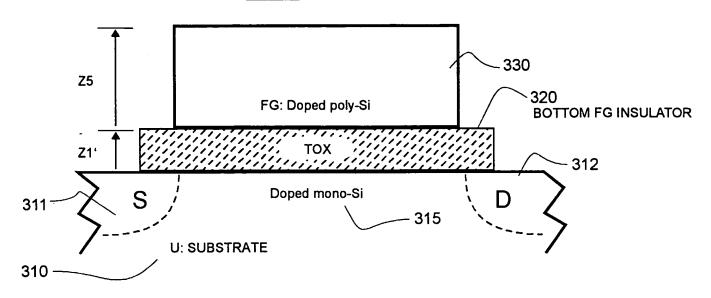


Fig. 3B

302 NITRIDATION

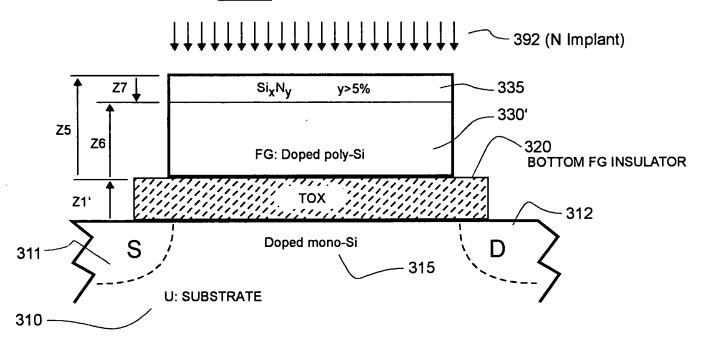


Fig. 3C

303 Atomic Layer Deposition of Intrinsic Si

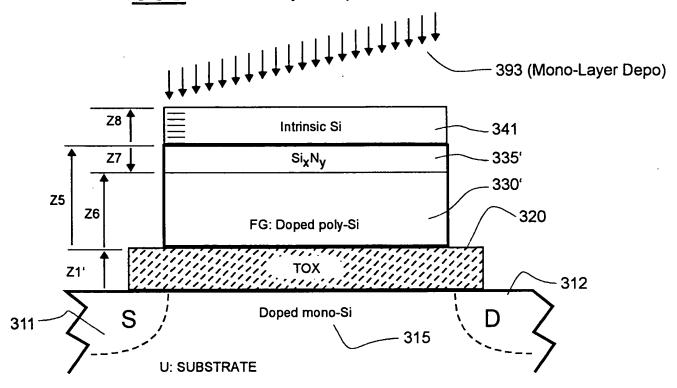


Fig. 3D

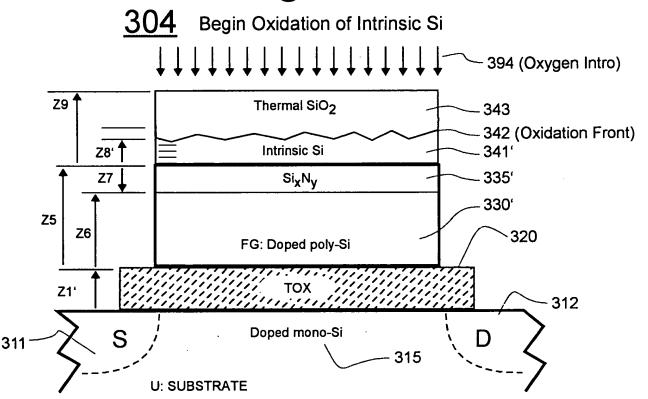
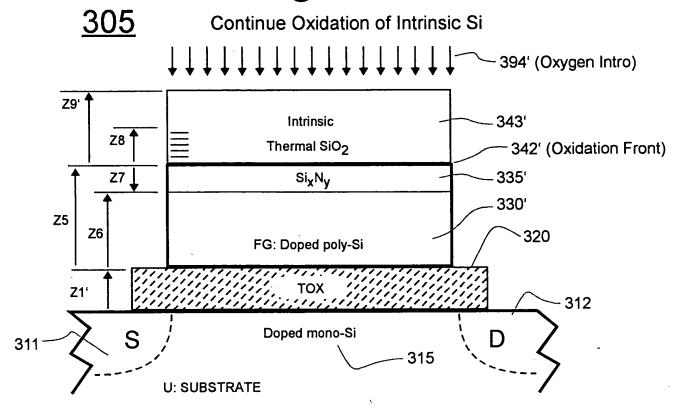


Fig. 3E



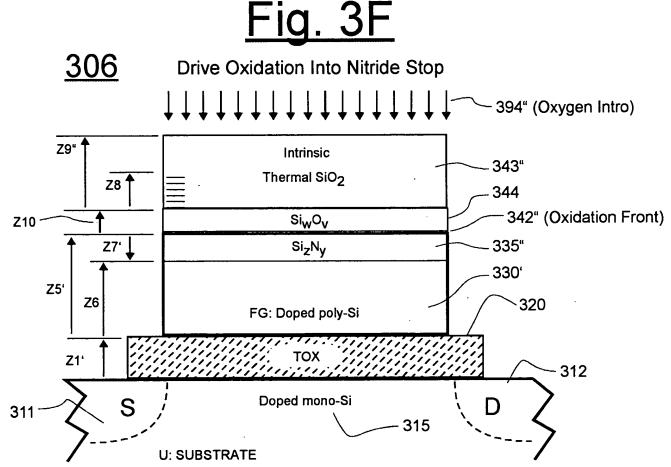
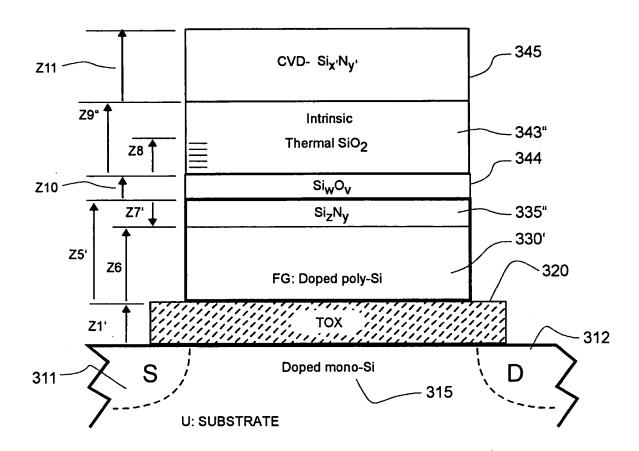


Fig. 3G

<u>307</u>

Deposit Middle SiN Layer





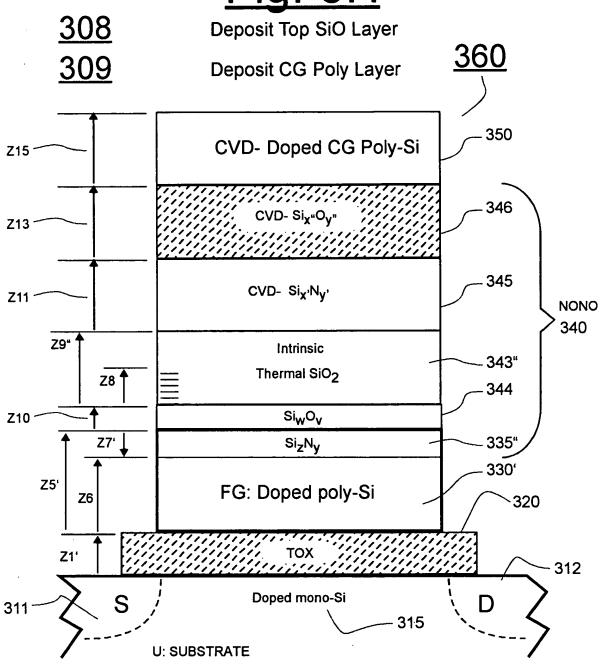


Fig. 4A

407 Atomic Layer Deposition of Intrinsic Si

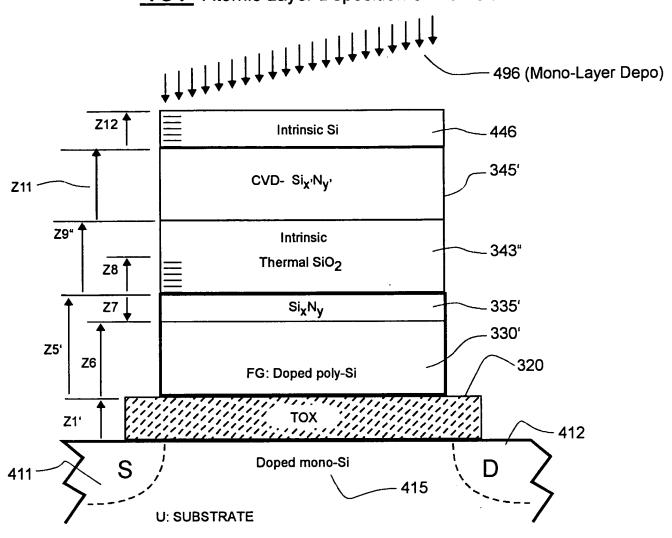
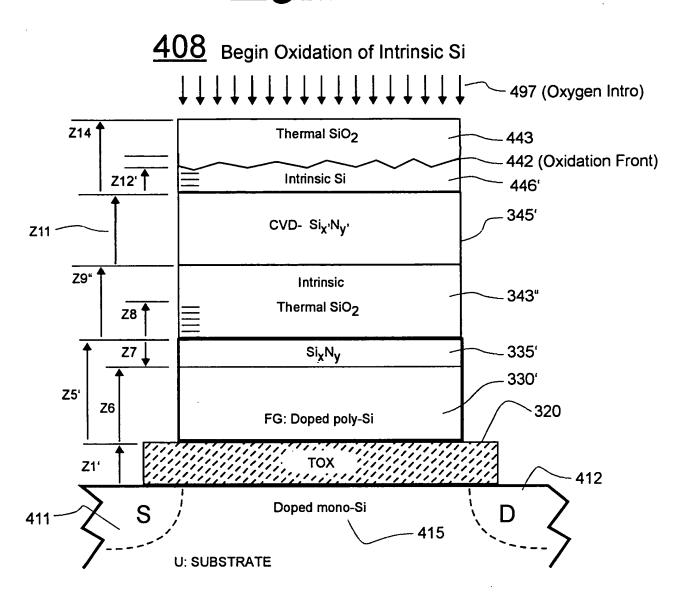
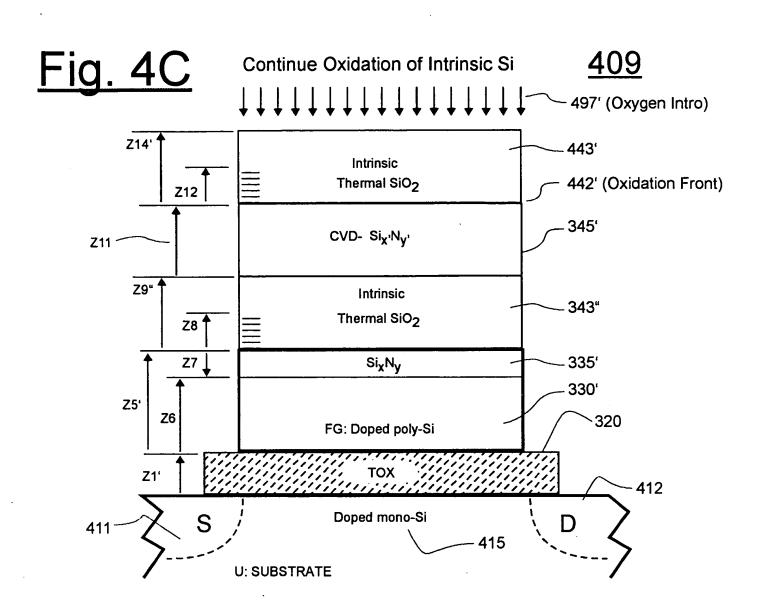


Fig. 4B





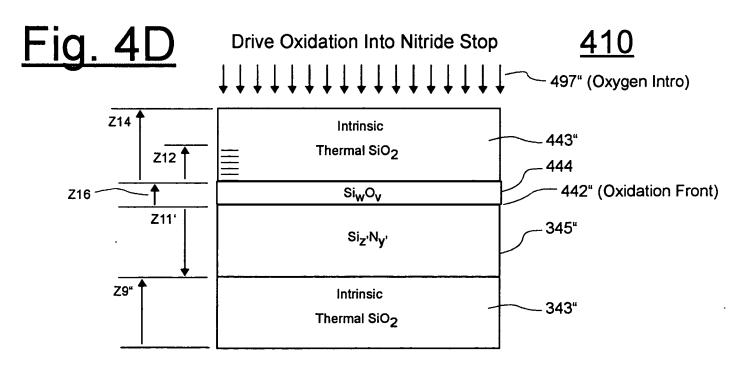


Fig. 4E

